

# iWOE 29

## 29th International Workshop on Oxide Electronics

The International Workshop on Oxide Electronics series has become an important venue to discuss recent advances and emerging trends in this developing field. The aim of the workshop is to provide an interdisciplinary forum for researchers - theorists as well as experimentalists - on understanding the fundamental electronic and structural properties and also the design, synthesis, processing, characterization, and applications of (epitaxial) functional oxide materials. Results of critical scientific importance as well as studies revealing the technological potential of functional oxide thin films to create devices with enhanced performance will be showcased.



<http://iwoe29.org>

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16<sup>th</sup> - 18<sup>th</sup>

OCTOBER 2023

Westin Josun Busan  
Busan, South Korea

### Important Dates

|                          |             |
|--------------------------|-------------|
| Abstract Submission Open | 5 JUN 2023  |
| Abstract Submission      | 14 JUL 2023 |
| Registration Open        | 18 JUL 2023 |
| Early Registration       | 1 SEP 2023  |

### Invited Speakers

Charles Ahn Yale Univ.  
Andrea Caviglia Univ. Geneva  
Si-Young Choi POSTECH  
Chang-Beom Eom UW-Madison  
Joseph Falson CALTECH  
Daisuke Kan Kyoto Univ.  
Hiroshi Kumigashira Tohoku Univ.

Sylvia Matzen Univ. Paris-Saclay  
Marisa Medarde Paul Scherrer Inst.  
Tae Won Noh Seoul Nat'l Univ.  
Ganesh Ji Omar Nat'l Univ. Singapore  
Asle Sudbo NTNU  
Pu Yu Tsinghua Univ.

### Program Committee

Woo Seok Choi Sungkyunkwan Univ.    Hyoungjeen Jeon Pusan Nat'l Univ.    Tae Won Noh Seoul Nat'l Univ.  
Kyeong Tae Kang Kyungpook Nat'l Univ.    Min Hyuk Park Seoul Nat'l Univ.    Junwoo Son POSTECH

### Supports

